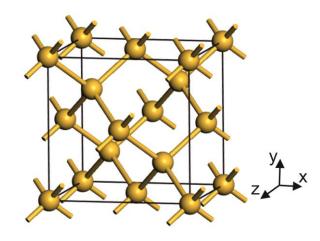
1	Corresponding author: V.V. Atuchin
2	Institute of Semiconductor Physics, Novosibirsk 630090, Russia
3	Phone: +7 (383) 3308889
4	E-mail: <u>atuchin@isp.nsc.ru</u>
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7	New candidate to reach Shockley–Queisser limit: the DFT study of
8	orthorhombic silicon allotrope Si(oP32)
9	A.S. Oreshonkov ^{1,2} , E.M. Roginskii, ³ V.V. Atuchin ^{4,5,6}
10	¹ Laboratory of Molecular Spectroscopy, Kirensky Institute of Physics Federal Research Center
11	KSC SB RAS, Krasnoyarsk 660036, Russia
12	² Siberian Federal University, Krasnoyarsk 660041, Russia
13	³ Laboratory of Spectroscopy of Solid State, Ioffe Institute, St. Petersburg 194021, Russia
14	⁴ Laboratory of Optical Materials and Structures, Institute of Semiconductor Physics, SB RAS,
15	Novosibirsk 630090, Russia
16	⁵ Functional Electronics Laboratory, Tomsk State University, Tomsk 634050, Russia
17	⁶ Research and Development Department, Kemerovo State University, Kemerovo 650000, Russia
18	
19	Abstract
20	In the present study, the unit cell parameters and atomic coordinates were predicted for the Pbcm
21	orthorhombic structure of Si(oP32) modification. This new allotrope of silicon is mechanically
22	stable and stable with respect to the phonon states. The electronic structure of Si(oP32) is calculated
23	for LDA and HSE06 optimized structures. The band gap value $E_g = 1.361$ eV predicted for
24	Si(oP32) is extremely close to the Shockley-Queisser limit and it indicates that the Si(oP32)
25	modification is a promising material for efficient solar cells. The frequencies of Raman and Infrared
26	active vibrations have been calculated for allotrope Si(oP32).

27 Keywords: Silicon, allotrope, Shockley–Queisser limit, DFT, phonon

1. Introduction

1

2 The diamond-like cubic silicon (Fig. 1) is a semiconductor with the indirect band gap equal to 3 1.12 eV [1,2]. This elemental material is abundant in nature and, due to its appropriate combination 4 of structural, chemical, mechanical and electronic properties, is widely used in modern electronics, 5 solar cells and chemical industry. Commonly, only the Si allotropes with amorphous and diamond-6 like structures are widely known as stable in ambient conditions. In the recent decades, the search 7 for new allotropes of Si has attracted considerable attention because most of chemical and physical 8 properties depend on the crystal structure, and it is reasonably expected that new crystal structures 9 might result in novel properties. As a result, many new thermodynamically stable silicon structures 10 were predicted and their properties were theoretically observed [3-11] including the cases when the 11 common tetragonal coordination of Si atoms transform into other forms [3,4,8]. Besides theoretical 12 investigations, the experimental studies were implemented with the use of different preparation 13 routes and several Si allotropes were synthesized to observe their structural and physical 14 characteristics [12-14].



15

16

Fig. 1. Crystal structures of cubic silicon

17 Recently, new germanium allotrope Ge(oP32) with the structure in space group *Pbcm* has 18 been synthesized by the mild-oxidation/delithiation of Li₇Ge₁₂ in ionic liquids [15]. The powder and 19 single crystal products were obtained by the reaction at 135-145 °C for several days. It is 20 particularly interesting that Ge(oP32) crystals are stable in ambient conditions. The allotrope has as 21 low direct optical band gap as $E_g = 0.33$ eV and is stable up to 363 °C. Thus, the transformation

1 from the diamond-like to orthorhombic structure results in a drastic band gap energy variation. As 2 for silicon, to the best of our knowledge, the related allotrope Si(oP32) has not been considered up 3 to now and its stability and properties remain unknown. Hence, the present study is aimed at the *ab* 4 *initio* calculations to evaluate the structure and physical properties of silicon allotrope Si(oP32) 5 isostructural to orthorhombic Ge(oP32).

6

2. Calculations

7 All the structural optimization, energy and vibrational calculation were carried out by the 8 CASTEP code using the density-functional theory [16]. The structure of orthorhombic Ge(oP32) 9 with the *Pbcm* space group was taken as the initial basis and the germanium atoms were replaced by 10 silicon ones [15]. This structure was fully optimized using the local density approximation (LDA) 11 provided by the Perdew and Zunger [17] parameterization of the numerical results of Ceperley and 12 Alder (CA-PZ) [18] and using the nonlocal exchange-correlation HSE06 functional [19].

13 The calculations of both cubic diamond-like and orthorhombic Pbcm structures were performed using the norm-conserving pseudopotential with $3s^2 3p^2$ electrons for Si atoms treated as 14 valence ones. The self-consistent field (SCF) procedure was used with a convergence threshold of 15 $5.0 \cdot 10^{-8}$ eV/atom. The total energy was corrected for the finite basis set with 3 cut-off energies. The 16 geometry optimizations were performed at the convergence threshold of 0.001 eV $Å^{-1}$ on the max 17 18 force, 0.01 GPa - on the max stress. The energy cutoff was set to be 900 eV, and the Brillouin zone (BZ) was sampled by $4 \times 3 \times 4$ and $6 \times 6 \times 6$ k-points using the Monkhorst-Pack scheme [20] for 19 20 orthorhombic and cubic structures, respectively. The electronic band structure was calculated within 21 the hybrid functional HSE06 method [16] as for the structure obtained after the geometry 22 optimization, using HSE06 as for the LDA relaxed structure. The phonon spectra at the Γ -point of 23 the BZ and Raman tensor components were calculated within the density functional perturbation 24 theory and the finite displacement method [21, 22] based on the crystal system type. The Raman spectra were simulated by the Lorentzian distribution with a fixed HWHM equal to 2 cm^{-1} . The 25 26 dispersion of phonon branches along high symmetry directions of the Brillouin zone was calculated 27 using the linear response method [23].

1 Ouasiparticle GW calculations [24] were performed using the ABINIT code [25,26]. The 2 one-shot G_0W_0 quasiparticle energies were computed using the Kohn-Sham eigenstates and 3 eigenvalues calculated within the LDA approximation as the initial solution of non-interacting Hamiltonian. The inverse dielectric matrix $\in_{GG'}^{-1}(q,\omega)$ was calculated by the random phase 4 approximation (RPA) using 192 unoccupied bands. The dynamic screening was calculated using the 5 6 contour deformation method [27]. The wavefunctions with maximal kinetic energy 35 Ha were used in the calculations. The corrections to Kohn-Sham energies were calculated as $\sum -E_{xc}$ operator 7 diagonal matrix elements, where $\sum = GW$ - self-energy operator, E_{xc} - exchange-correlation energy 8 operator, G - Green function, and $W = e^{-1} v$ - screening Coulomb interaction operator. The 9 components of wavefunction with energies below 750 eV for both exchange and correlation parts 10 11 were used to calculate Σ .

12

3. Results and discussion

13 The optimized crystal structure of Si(oP32) is shown in Figure 2 and the obtained 14 crystallographic data are summarized in Table 1. The difference between the calculated unit cell 15 parameters using LDA and HSE06 does not exceed 0.016 Å. The obtained fractional coordinates 16 differ only in the third decimal place.

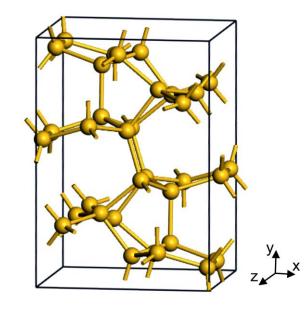




Fig. 2. Crystal structures of predicted silicon allotrope Si(oP32).

1 Table 1. The calculated structural parameters and atomic positions of Si(oP32), as obtained by

		Unit cell param	eters			
	<i>a</i> , Å	b, Å	<i>c</i> , Å			
	7.777625	11.194104	7.387129			
	(7.785639)	(11.186565)	(7.402904)			
Atom	Wyckoff site	Fractional atomic coordinates				
Si1	4d	0.56517	0.08464	0.25000		
		(0.56592)	(0.08406)	(0.25000)		
Si2	4d	0.33135	0.22142	0.25000		
		(0.33106)	(0.22017)	(0.25000)		
Si3	4d	0.48543	-0.11273	0.25000		
		(0.48599)	(-0.11346)	(0.25000)		
Si4	8e	-0.02380	0.41322	0.08613		
		-0.02378	(0.41340)	(0.08639)		
Si5	4c	0.15389	0.25000	0.00000		
		(0.15405)	(0.25000)	(0.00000)		
Si6	8e	0.69943	0.14703	-0.01212		
		(0.69939)	(0.14682)	(-0.01221)		

2 LDA and HSE06 (shown in parentheses)

3

8

The mandatory part of mechanical stability of a crystal lattice is the calculations of elastic constants and elastic moduli [28, 29]. The elastic behavior of a lattice is described by the secondorder elastic constant matrix C_{ij} [30]. The calculated stiffness matrix C_{ij} of orthorhombic *Pbcm* silicon is presented below.

$$C_{ij} \! = \! \begin{pmatrix} 146.07 & 45.46 & 51.31 \\ 45.46 & 154.12 & 39.23 \\ 51.31 & 39.23 & 181.75 \\ & & & 44.18 \\ & & & 55.08 \\ & & & & 45.76 \end{pmatrix}$$

9 The *necessary* and *sufficient* Born criteria for an orthorhombic system stability [30] are 10 $C_{11}>0$, $C_{11}C_{22}>C_{12}^2$, $C_{11}C_{22}C_{33}+2C_{12}C_{13}C_{23} - C_{11}C_{23}^2 - C_{22}C_{13}^2 - C_{33}C_{12}^2>0$, $C_{44}>0$, $C_{55}>0$, $C_{66}>0$. 11 All the above conditions are satisfied for the predicted orthorhombic structure. Thus, the predicted 12 structure of Si(oP32) allotrope is stable with respect to elastic properties. The calculated bulk 13 modulus (*B*) value is found to be equal to 83.19 GPa. The results obtained in this work for cubic silicon: *B*=98.00 GPa and *C*₁₁=163.97 GPa, *C*₁₂=65.02 GPa, *C*₄₄=77.39 GPa are in accordance with
 experimental data: *B*=98 GPa [31] and *C*₁₁=166 GPa, *C*₁₂=64 GPa, *C*₄₄=79.6 GPa [32].

3 The electronic band structure calculations were performed for the LDA and HSE06 relaxed 4 structures of orthorhombic *Pbcm* and cubic silicon allotropes. As expected, the strong the band gap 5 value underestimation is found in the local density approximation for the cubic phase. Thus, one 6 may assume that LDA fails to threat the electronic structure of crystalline Si. On the contrary, the 7 good agreement is found in case of geometry optimization using the HSE06 method followed by the electronic structure calculations using HSE06 also. The calculated E^{i}_{g} value for cubic silicon is in 8 9 excellent agreement with the experimental ones (1.12 eV [1,2,30.2]) obtained using the hybrid 10 functional HSE06 method for the structure optimized by the local density approximation. This fact 11 could be used as a good validation of the methods, and, hence, predicted values could be used as a 12 reference for the orthorhombic Si(oP32) allotrope. The calculated data obtained with different approaches are shown in Table 2. 13

Table 2. Calculated indirect band gap values (in eV) for cubic and orthorhombic *Pbcm* silicon
allotropes

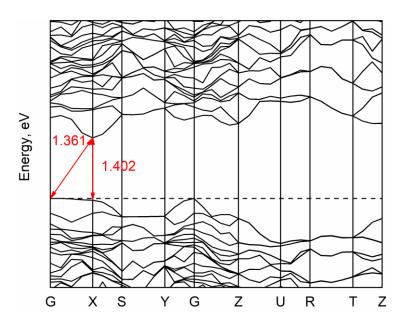
	Cubic			Orthorhombic Pbcm			
Functional for geom. opt.	LDA	LDA	HSE06	LDA	LDA	HSE06	
Functional for band str. calc.	LDA	HSE06	HSE06	LDA	HSE06	HSE06	
$E^{i}_{g}(eV)$	0.479	1.113	1.078	0.695	1.361	1.383	

16

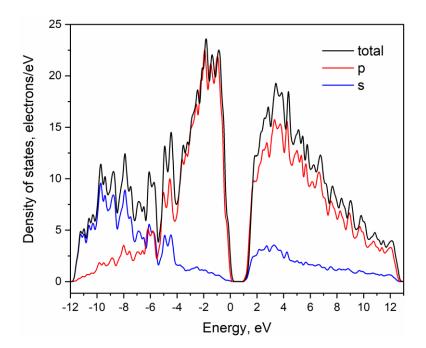
The electronic band structure of Si(oP32) calculated by the hybrid functional HSE06 method for the LDA relaxed structure is plotted in Figure 3. For the energy band calculations, the highsymmetry points of the BZ are selected as G-X-S-Y-G-Z-U-R-T-Z. The coordinates of the special points of the Brillouin zone are: G(0,0,0), X(0.5,0,0), S(0.5,0.5,0), Y(0,0.5,0), Z(0,0,0.5), U(0.5,0,0.5), R(0.5,0.5,0.5), T(0,0.5,0.5). It is found that the valence band (VBM) top is well localized in the vicinity of the Γ -point in the center of the Brillouin zone. The conduction band (CBM) bottom is located at X-point (0.5, 0, 0). The band gap value for the indirect electronic

transitions calculated within the hybrid functional HSE06 approach is equal to $E_g^i = 1.361$ eV. It is 1 2 noteworthy to mention that the predicted Si(oP32) band gap value is very close to the theoretical 3 value of Shockley-Queisser limit (1.34 eV) [33, 34]. Respectively, the Si(oP32) silicon 4 modification seems to be a promising material for solar cells. The direct band gap is located at the Y-point of the Brillouin zone and the calculated band gap value is $E_{g}^{d} = 1.402 \text{ eV}$. The results of 5 6 quasi-particle $G_0 W_0$ approximation are in agreement with the result of hybrid HSE06, and the 7 difference between direct and indirect band gap values is insignificant, too (0.045 eV). However, there is a slight divergence in the band gap values of G_0W_0 approximation ($E_g^i = 1.127$ eV), with 8 respect to HSE06 calculations ($E_g^i = 1.362 \text{ eV}$), which is probably due to the fact that $G_0 W_0$ was 9 10 performed as "one-shot" calculations, while the calculations with the hybrid functional HSE06 approach were made as self-consisted. Thus, as a result of the electronic band structure analysis, we 11 can conclude that Si(oP32) is a semiconductor material with indirect band gap $E_g^i = 1.362$ eV. The 12 difference between direct and indirect band gaps is negligible. 13

The total and partial density of states of the Si(oP32) silicon allotrope structure obtained with the LDA method are shown in Figure 4. As a result of the curve analysis, one can find that the VBM and CBM are constructed mostly by the p-electrons of Si atoms, and s-electrons play a secondary role in the CBM formation.



19 Figure 3. Electronic band structure of Si(oP32) silicon calculated with the use of HSE06.



1

Figure 4. Total and partial density of states of Si(oP32).

The mechanical representation for the predicted Si(oP32) allotrope phase of Si (*Pbcm*) at the Brillouin zone center is $\Gamma_{vibr} = 13A_g + 10A_u + 14B_{1g} + 11B_{1u} + 11B_{2g} + 14B_{2u} + 10B_{3g} + 13B_{3u}$ [35] where the Raman active modes are $\Gamma_{Raman} = 13A_g + 14B_{1g} + 11B_{2g} + 10B_{3g}$, and the infrared active modes are $10B_{1u} + 13B_{2u} + 12B_{3u}$. The acoustic modes are $\Gamma_{Acoustic} = B_{1u} + B_{2u} + B_{3u}$. Thus, the Raman spectra of *Pbcm* silicon allotrope contain much more bands than that of cubic silicon. Cubic silicon has only one BZ center optical phonon mode active in the Raman spectrum at 522 cm⁻¹ [36].

9 The calculated Raman spectrum of Si(oP32) allotrope is shown in Figure 5. The spectral line with the highest wavenumber value (533.6 cm^{-1}) is related to the stretching vibration of the shortest 10 11 bond in the structure (Si1-Si3, see Fig. 6a) and, according to the calculation data, the stretching-like vibrations of different Si-Si pairs are located in the rage of 463–533 cm⁻¹. The various stretching-12 like and bending-like vibrations of structural units (Fig. 6b) are located in the range of 323-457 cm⁻ 13 14 ¹. The weak band at 291.5 cm⁻¹, the most intensive band in the calculated Raman spectrum at 278.1 cm⁻¹ and a very weak band at 196.1 cm⁻¹ are related to the stretching of the structure as a whole, as 15 shown in Fig. 6c, Fig. 6d, Fig. 6e correspondingly. The intense line at 129.0 cm⁻¹ is a vibration of 16 17 Si chains, as shown in Fig. 6f.

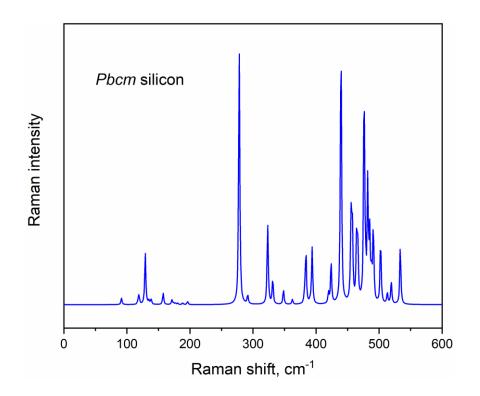


Figure 5. Calculated Raman spectrum of Si(oP32).

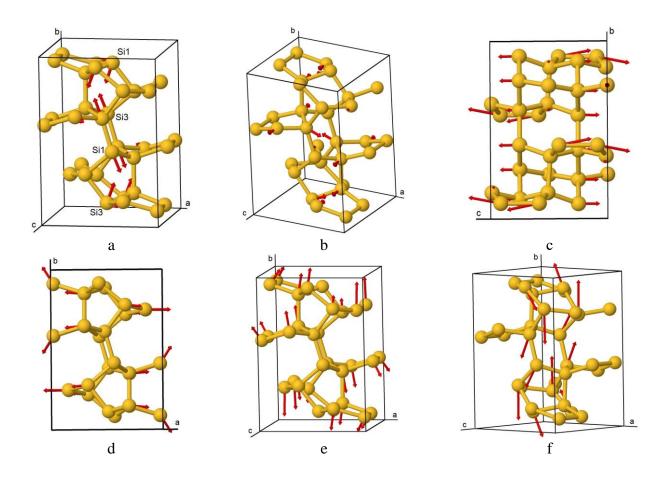




Figure 6. Displacements of Si(oP32) atoms in the vibrations with frequencies of 533.6 cm⁻¹ (a),
446.7 cm⁻¹ (b), 291.5 cm⁻¹ (c), 278.1 cm⁻¹ (d), 196.1 cm⁻¹ (e) and 129.0 cm⁻¹ (f).

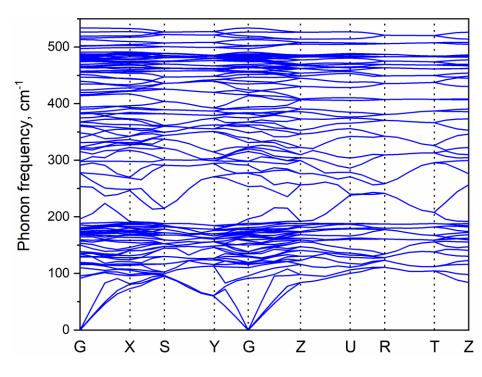
It is worth noting that the orthorhombic Si(oP32) has the IR-active phonons, opposite to cubic silicon. The dynamical properties calculation was carried out and the simulated wavenumbers of Raman and Infrared active modes are listed in Table 3. The calculated phonon dispersion of Si(oP32) structure is shown in Figure 7. There are no phonon branches with imaginary frequencies, and, hence, the predicted structure should be stable with respect to phonon states.

6

Table 3. The calculated vibrational wavenumber values (cm⁻¹) of Si(oP32) allotrope

		5				T 0		
N⁰	Raman				Infrared			
	A_g	B_{1g}	B_{2g}	B_{3g}	A_u	B_{1u}	B_{2u}	B_{3u}
1	533.6	519.3	502.4	513.0	501.4	497.2	526.3	515.6
2	490.7	481.4	485.0	487.8	477.0	482.9	486.3	482.2
3	481.9	476.2	478.3	469.2	463.3	474.2	479.0	481.3
4	457.4	464.4	466.2	463.1	451.7	413.9	434.7	465.6
5	455.4	446.6	390.4	419.7	367.2	382.9	415.7	456.0
6	439.5	423.8	348.3	362.5	315.4	185.6	367.5	374.8
7	393.7	382.0	188.4	291.5	178.3	169.2	360.1	339.4
8	383.9	331.2	177.2	176.7	170.5	153.2	320.0	322.4
9	323.2	277.2	138.2	157.4	138.0	130.6	298.2	297.9
10	278.1	196.1	119.0	117.4	110.0	115.8	159.2	253.5
11	171.3	180.6	95.9				150.2	173.3
12	129.0	174.0					135.2	167.4
13	91.3	164.6					119.5	
14		134.7						

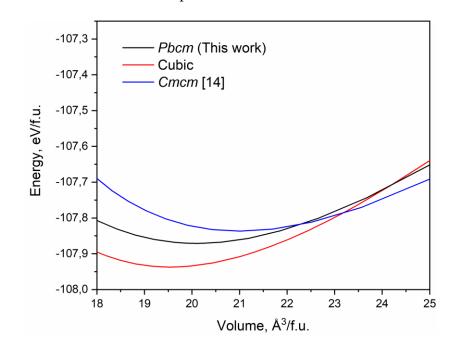




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Figure 7. Calculated phonon dispersion curves of the Si(oP32) allotrope of silicon.

Earlier, other orthorhombic allotrope of silicon with the structure in space group *Cmcm* was investigated [14]. In Fig. 8, the energy of the relaxed geometries of cubic and orthorhombic *Pbcm* and *Cmcm* structures as a function of volume per formula unit is shown.



4

5 Fig. 8. Total energy per formula unit (f.u.) as a function of the volume per f.u. for cubic and
6 orthorhombic structures of silicon.

7 It is clearly seen that the phase transition from cubic to orthorhombic structures with Cmcm 8 and *Pbcm* spase groups may occur in the case of increasing the volume of per formula unit of cubic 9 silicon. These curves intersection points relate to the ~18.2 and ~23.8 percent increase of the cubic 10 silicon cell volume. As a possible way of such structure expansion, an intercalation of neutral atoms 11 into the cubic silicone structure may be considered. Herewith, the cubic structure still remains to be 12 stable, with respect to elastic stability conditions and phonon states. Thus, such possible phase 13 transitions should be of the first order type. As evident in Figure 8, the intersection of the energy per 14 volume curves for *Cmcm* and *Pbcm* phases exist and, thus, the structural transformation is possible 15 from Si₂₄ to the Si(oP32) allotrope. Si₂₄ (orthorhombic Cmcm) silicon was experimentally obtained as a result of thermal `degassing' of Na₄Si₂₄ at 400 K under dynamic vacuum [14]. Ge(oP32) 16 17 (orthorhombic *Pbcm*) germanium was experimentally prepared by the treatment of Li₇Ge₁₂ in ionic 18 liquids [15]. The processes appropriate for the Li intercalation into cubic silicon are well known and, supposedly, they could be developed to reach the Li₇Si₁₂ phase [37-40]. Thus, it may be suggested that similar chemical reactions can also be designed for the formation of Si(oP32) modification. In terms of the total energy minimum, from results of our research follows that the total energy per formula unit for the Si(oP32) structure of orthorhombic silicon predicted in this work is lower than the one for *Cmcm* silicon. Thus, it can be reasonably assumed that the *Pbcm* phase is preferable than the *Cmcm* phase at ambient conditions.

7

4. Conclusions

8 In the present study, the unit cell parameters and atomic coordinates were predicted for a 9 new anisotropic modification Si(oP32) of silicon. The Si(oP32) allotrope structure is similar to that 10 of earlier synthesized germanium allotrope Ge(oP32). Respectively, because of chemical and 11 structural similarities, the existence of continuous series of solid solutions Si(oP32)-Ge(oP32) can 12 be assumed. The band gap value $E_g = 1.361$ eV predicted for Si(oP32) is very close to the 13 Shockley-Queisser limit and it indicates that the silicon modification is a promising material for 14 efficient solar cells. Thus, this is the time for the experimental synthesis of Si(oP32) allotrope and 15 detailed exploration of their properties.

16 Acknowledgements

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